



Title of Change:	Hydrazine elimination and 5-inch Production line closure at ON Semiconductor Niigata Co., Ltd. (OSNC).																			
Proposed first ship date:	2 March 2019																			
Contact information:	Contact your local ON Semiconductor Sales Office or <Tetsuya.Fukushima@onsemi.com>																			
Samples:	Samples should be available after completion of qualification. Contact your local ON Semiconductor Sales Office.																			
Type of notification:	<p>This is an Initial Product/Process Change Notification (IPCN) sent to customers. IPCNs are issued at least 30 days prior to the issuance of the Final Change Notice (FPCN). An IPCN is an advance notification about an upcoming change and contains general information regarding the change details and devices affected. It also contains the preliminary reliability qualification plan.</p> <p>The completed qualification and characterization data will be included in the Final Product/Process Change Notification (FPCN). This IPCN notification will be followed by a Final Product/Process Change Notification (FPCN) at least 90 days prior to implementation of the change. In case of questions, contact <PCN.Support@onsemi.com>.</p>																			
Change Part Identification:	Date Code																			
Change category:	<input checked="" type="checkbox"/> Wafer Fab Change <input type="checkbox"/> Assembly Change <input type="checkbox"/> Test Change <input type="checkbox"/> Other _____																			
Change Sub-Category(s):	<input type="checkbox"/> Manufacturing Site Change/Addition <input type="checkbox"/> Material Change <input type="checkbox"/> Datasheet/Product Doc change <input checked="" type="checkbox"/> Manufacturing Process Change <input type="checkbox"/> Product specific change <input type="checkbox"/> Shipping/Packaging/Marking <input type="checkbox"/> Other: _____																			
Sites Affected:	ON Semiconductor Sites: ON Niigata, Japan	External Foundry/Subcon Sites: None																		
Description and Purpose:																				
<p>This announces the 5-inch production line closure due to the supply risk for 5-inch substrates from our wafer manufacturers as well constraints resulting from the aging of 5-inch production equipment.</p> <p>Hydrazine was identified as a prohibited chemical in ON Semiconductor as it is considered as a carcinogenic substance and has high risk of fire and explosion.</p> <p>Relevant products will get transferred to a 6-inch production line that do not use Hydrazine within the same site, ON Semiconductor Niigata Co., Ltd. (OSNC).</p>																				
	<table border="1"> <thead> <tr> <th>Change Point</th> <th>Before Change Description</th> <th>After Change Description</th> </tr> </thead> <tbody> <tr> <td>Fab (OSNC)</td> <td>N1 Fab (Minimum rule=0.8um, Class=100)</td> <td>N1 Fab (Minimum rule=0.8um, Class=100) AND N2 Fab (Minimum rule=0.25um, Class=10)</td> </tr> <tr> <td>Equipment</td> <td>5inch equipment</td> <td>6inch equipment (Each function is the same)</td> </tr> <tr> <td>Si Sub material</td> <td>5inch wafer</td> <td>6inch wafer (No change except wafer diameter)</td> </tr> <tr> <td>Wire material</td> <td>Aluminum (without Anti-reflected Layer)</td> <td>Aluminum (with Anti-reflected Layer)</td> </tr> <tr> <td>Interlayer material</td> <td>Silicon nitride and Polyimide or Polyimide</td> <td>Silicon nitride and Silicon oxide or Oxide</td> </tr> </tbody> </table>		Change Point	Before Change Description	After Change Description	Fab (OSNC)	N1 Fab (Minimum rule=0.8um, Class=100)	N1 Fab (Minimum rule=0.8um, Class=100) AND N2 Fab (Minimum rule=0.25um, Class=10)	Equipment	5inch equipment	6inch equipment (Each function is the same)	Si Sub material	5inch wafer	6inch wafer (No change except wafer diameter)	Wire material	Aluminum (without Anti-reflected Layer)	Aluminum (with Anti-reflected Layer)	Interlayer material	Silicon nitride and Polyimide or Polyimide	Silicon nitride and Silicon oxide or Oxide
Change Point	Before Change Description	After Change Description																		
Fab (OSNC)	N1 Fab (Minimum rule=0.8um, Class=100)	N1 Fab (Minimum rule=0.8um, Class=100) AND N2 Fab (Minimum rule=0.25um, Class=10)																		
Equipment	5inch equipment	6inch equipment (Each function is the same)																		
Si Sub material	5inch wafer	6inch wafer (No change except wafer diameter)																		
Wire material	Aluminum (without Anti-reflected Layer)	Aluminum (with Anti-reflected Layer)																		
Interlayer material	Silicon nitride and Polyimide or Polyimide	Silicon nitride and Silicon oxide or Oxide																		

**Qualification Plan:**QV DEVICE NAME LV5609V-TLM-EPACKAGE SSOP20 (225mil)

Test	Specification	Condition	Interval
HTOL	JESD22-A108	Tj=150°C, 100 % max rated Vcc	1008 hrs
HTSL	JESD22-A103	Ta= 150°C	1008 hrs
TC	JESD22-A104	Ta= -65°C to +150°C	500 cyc
THB	JESD22-A101	85°C, 85% RH, bias	1008 hrs
uHAST	JESD22-A118	130°C, 85% RH, 18.8psig,	96 hrs
PC	J-STD-020 JESD-A113	MSL 3 @ 260 °C	-
HBM	JS001	100pF,1.5kohm	-
CDM	JS002		-

QV DEVICE NAME LV8804FV-TLM-HPACKAGE SSOP20 (225mil)

Test	Specification	Condition	Interval
HTOL	JESD22-A108	Tj=150°C, 100 % max rated Vcc	1008 hrs
HTSL	JESD22-A103	Ta= 150°C	1008 hrs
TC	JESD22-A104	Ta= -65°C to +150°C	500 cyc
THB	JESD22-A101	85°C, 85% RH, bias	1008 hrs
uHAST	JESD22-A118	130°C, 85% RH, 18.8psig,	96 hrs
PC	J-STD-020 JESD-A113	MSL 3 @ 260 °C	-
HBM	JS001	100pF,1.5kohm	-
CDM	JS002		-

List of Affected Standard Parts:

Part Number	Qualification Vehicle
LV5609LP-E	LV5609V-TLM-E
LV5609LP-TE-L-E	LV5609V-TLM-E
LV5609V-TLM-E	LV5609V-TLM-E
LV8804FV-TLM-H	LV8804FV-TLM-H
LV8805SV-TLM-H	LV8804FV-TLM-H

Appendix A: Changed Products

Product	Customer Part Number	Qualification Vehicle
LV5609LP-E		LV5609V-TLM-E
LV5609LP-TE-L-E		LV5609V-TLM-E
LV5609V-TLM-E		LV5609V-TLM-E
LV8804FV-TLM-H		LV8804FV-TLM-H
LV8805SV-TLM-H		LV8804FV-TLM-H